

DOCKET NO: 278426US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :

MITSUGU ABE, ET AL. : EXAMINER: ROSE, R.

SERIAL NO: 10/549,294 :

FILED: SEPTEMBER 16, 2005 : GROUP ART UNIT: 3723

FOR: MATERIAL FOR PURIFICATION  
OF SEMICONDUCTOR POLISHING  
SLURRY, MODULE FOR PURIFICATION  
OF SEMICONDUCTOR POLISHING  
SLURRY AND PROCESS FOR  
PRODUCING SEMICONDUCTOR  
POLISHING SLURRY

DO NOT ENTER: /RR/

03/25/2008

AMENDMENT

COMMISSIONER FOR PATENTS  
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Final Rejection dated November 16, 2007, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 9 of this paper.